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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/560,717	12/15/2005	Freddy Roozeboom	NL 040226	8503	
65913 NXP. B.V.	7590 05/27/20	11	EXAM	EXAMINER	
NXP INTELLECTUAL PROPERTY & LICENSING			CHEN, I	CHEN, DAVID Z	
M/S41-SJ 1109 MCKAY DRIVE		ART UNIT	PAPER NUMBER		
SAN JOSE, CA 95131			2815		
			NOTIFICATION DATE	DELIVERY MODE	
			05/27/2011	ELECTRONIC	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

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Advisory Action Before the Filing of an Appeal Brief

Application No.	Applicant(s)	
10/560,717	ROOZEBOOM ET AL.	
Examiner	Art Unit	
DAVID CHEN	2815	

	DAVID CHEN	2815					
The MAILING DATE of this communication appe	ears on the cover sheet with the o	orrespondence add	ress				
THE REPLY FILED 04 May 2011 FAILS TO PLACE THIS APPLICATION IN CONDITION FOR ALLOWANCE.							
 M The reply was flied after a final rejection, but prior to or on application, applicant must timely flie one of the following application in condition for allowance; (2) a Notice of App for Continued Examination (RCE) in compliance with 37 (periods: 	the same day as filing a Notice of a replies: (1) an amendment, affidavil eal (with appeal fee) in compliance	Appeal. To avoid abar , or other evidence, v with 37 CFR 41.31; or	hich places the (3) a Request				
a) The period for reply expiresmonths from the mailing	date of the final rejection.						
b) The period for reply expires on: (1) the mailing date of this Advisory Action, or (2) the date set forth in the final rejection, whichever is later. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of the final rejection. Examiner Note: (fb ox 1 is checked, check either box (a) or (b), ONLY ORECK BOX (b) WHEN THE FIRST REPLY WAS FILED WITHIN TWO							
MONTHS OF THE FINAL REJECTION. See MFEP 706.07(f).							
Extensions of time may be obtained under 37 CFR 1.136(a). The date on which the petition under 37 CFR 1.136(a) and the appropriate extension fee have been filled is the date for purposes of determining the period of extension and the corresponding amount of the fee. The appropriate extension fee under 37 CFR 1.17(a) is calculated from: (1) the expiration date of the shortened statutory period for reply originally set in the final Office action: or (2) as set for thin (b) above; it checked. Any reply received by the Office later than three months after the mailing date of the final rejection, even if timely filled, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). NOTICE OF APPEAL							
2. The Notice of Appeal was filed on A brief in comp	liance with 37 CFR 41.37 must be t	iled within two month	s of the date of				
filling the Notice of Appeal (37 CFR 41.37(a)), or any extension thereof (37 CFR 41.37(e)), to avoid dismissal of the appeal. Since a Notice of Appeal has been filed, any reply must be filed within the time period set forth in 37 CFR 41.37(a).							
<u>AMENDMENTS</u>							
 ∑ The proposed amendment(s) flied after a final rejection, but prior to the date of filing a brief, will not be entered because (a) ∑ They raise new issues that would require further consideration and/or search (see NOTE below); (b) ∑ They raise the issue of new matter (see NOTE below); 							
(c) They are not deemed to place the application in better form for appeal by materially reducing or simplifying the issues for appeal; and/or							
(d) They present additional claims without canceling a		cted claims.					
NOTE: <u>Claim 28</u> . (See 37 CFR 1.116 and 41.33(a							
4. The amendments are not in compliance with 37 CFR 1.1:		npliant Amendment (PTOL-324).				
5. Applicant's reply has overcome the following rejection(s):							
6. Newly proposed or amended claim(s) would be allowable if submitted in a separate, timely filed amendment canceling the non-allowable claim(s).							
7. ∑ For purposes of appeal, the proposed amendment(s): a) ∑ will not be entered, or b) ☐ will be entered and an explanation of how the new or amended claims would be rejected is provided below or appended. The status of the claim(s) is (or will be) as follows:							
Claim(s) allowed: Claim(s) objected to: 2,4 and 9.							
Claim(s) objected to: <u>2.4 and 9.</u> Claim(s) rejected: <u>1.3.5-8.10 and 20-27.</u>							
Claim(s) withdrawn from consideration:							
AFFIDAVIT OR OTHER EVIDENCE							
 The affidavit or other evidence filed after a final action, bu because applicant failed to provide a showing of good and was not earlier presented. See 37 CFR 1.116(e). 							
 The affidavit or other evidence filed after the date of filing entered because the affidavit or other evidence failed to o showing a good and sufficient reasons why it is necessar 	vercome all rejections under appea	I and/or appellant fail	s to provide a				
10. The affidavit or other evidence is entered. An explanation of the status of the claims after entry is below or attached. REQUEST FOR RECONSIDERATION/OTHER							
The request for reconsideration has been considered bu <u>See Continuation Sheet.</u>	t does NOT place the application in	condition for allowan	ce because:				
12. Note the attached Information <i>Disclosure Statement</i> (s). 13. Other:	(PTO/SB/08) Paper No(s)						
/D, C./							
Examiner, Art Unit 2815	/MATTHEW E WARREI Primary Examiner, Art U						

Continuation of 11, does NOT place the application in condition for allowance because: Applicants argue "This reliance upon the '769 reference appears to be a new grounds for rejection, which renders the finality of the instant Office Action improper." This is not found persuasive because the '769 reference that is incorporated by reference by the '481 reference is used in response to Applicants' argument filled on February 03, 2011. The '481 reference does not explicitly disclose the formation of the via structure beauth the '769 reference that is incorporated by reference discloses the formation of the via. The '769 reference does not modify the '481 reference but further supports the disclosure in the '481 reference.

Applicants further argue "This statement does not appear to address Applicants' traversals regarding the 481 teaching away from the proposed combination (and would remain uncontroverted in the record for the purpose of appeal)". This is not und persussive because as discussed under Response to Arguments in the Final Office Action mailed on March 04, 2011, although the '481 reference discloses the trench capacitor may be preferred to be formed at a different step than the interconnect in the case where the high k insulator in the trench capacitor is not compatible with the conductors in the interconnect, the '481 reference does not limit one of ordinary skill in the art to form the device structure when there is no compatibility issue and thus forming the device structure under the circumstances that there is always a compatibility issue by stating it is enterly 'preferred' to form the trench capacitor at a different step than the interconnect. Thus, the '481 reference does not teach away when a single deposition is applied with the motivation provided by Gambino. Further as discussed under Response to Arguments, the '481 reference discloses the vertical interconnect is used as decoupling capacitor by using a high dielectric constant insulator as in the trench capacitor. In view of such structure, both the vertical interconnect and the trench capacitor are implemented as capacitor structures with using high k insulators. Thus, there inherently should not have any compatibility issue when forming these structures and the single deposition layer structure can be obtained to have the same electric qualities and no additional step for protection is required.

Applicants further argue "The Final Office Action fails to provide any explanation or proof that this modification is possible, only offering a statement that it could be done. Because the Final Office Action lacks any articulated reasoning for the proposed motivation, the rejections must fail". This is not found persuasive because Gambino specifically discloses forming the vias and the capacitor structures with a single deposition layer with the motivation of reducing lithography states (See Column 2, lines 38-42, Column 6, lines 48-53).

Applicants further argue "Referring to Col. 3-28-49, the conductive material 25 is deposited on the oxide layer 24, and thus cannot have walls with dielectric thereupon in accordance with the dalimed invention". This is not found persuasive because as clearly seen in Fig. 2D in the '970 reference, the vertical interconnect (25) having walls (left and right) on the sindle deposition layer of dielectric material (24).